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## What is claimed is:

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1. An evaporation method, comprising:

providing a substrate, fixing the center of the substrate and rotating the substrate; defining a circular trace by the center of the substrate;

providing a heater;

providing a source supplying device, wherein the source supplying device supplies an evaporation source to the heater along a supplying direction;

disposing the heater and the source supplying device under a point of the circular trace and adjusting the supplying direction of the source supplying device for paralleling the supplying direction and a tangential direction of the point of the circular trace; and

heating the evaporation source by the heater for evaporation.

- 2. The evaporation method of claim 1, further comprising disposing a shelter between the source supplying device and the substrate for defining an evaporation region.
  - 3. The evaporation method of claim 2, wherein a radius of the evaporation region is substantially similar to that of the circular trace.
  - 4. The evaporation method of claim 1, wherein a rotational direction of the substrate is clockwise.

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- 5. The evaporation method of claim 1, wherein a rotational direction of the substrate is counterclockwise.
- 6. The evaporation method of claim 1, wherein the evaporation source is aluminum or silver.
  - 7. An evaporation apparatus for depositing a film on a substrate, the evaporation apparatus comprising:
- a rotator fixing the center of a substrate and rotating the substrate to define a circular trace;
  - a heater, disposed under a point of the circular trace; and
  - a source supplying device, disposed over the heater, wherein the source supplying device supplies an evaporation source to the heater along a supplying direction and the supplying direction is parallel to a tangential direction of the circular trace.
  - 8. The evaporation apparatus of claim 7, further comprising a shelter disposed between the source supplying device and the substrate for defining the evaporation region, wherein the shelter has an opening for defining the evaporation region on the substrate.
  - 9. The evaporation apparatus of claim 8, wherein the opening is a circular opening.

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- 10. The evaporation apparatus of claim 9, wherein a radius of the evaporation region is substantially similar to that of the circular trace.
- 11. The evaporation apparatus of claim 7, wherein the evaporation source is aluminum or silver.
  - 12. The evaporation apparatus of claim 7, wherein a rotational direction of the substrate is clockwise.
- 13. The evaporation apparatus of claim 7, wherein a rotational direction of the substrate is counterclockwise.
  - 14. The evaporation apparatus of claim 7, wherein the heater is a rectangular loading crucible.